

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	4474	"438"/\$.ccls. and damascene and (first seed metal) with (plasma CVD IMP SIP)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/18 15:14
L3	2978	"438"/\$.ccls. and damascene and (first seed metal) adj3 (layer film) with (plasma CVD IMP SIP)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/18 15:16
L4	244	"438"/\$.ccls. and damascene and barrier adj3 (film layer metal) and first adj2 (seed metal conductive) same plasma and second adj2 (seed metal conductive)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/18 15:47
L8	316	"257"/\$.ccls. and damascene and barrier adj3 (film layer metal) and first adj2 (seed metal conductive) same plasma and second adj2 (seed metal conductive)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/18 15:55
L9	2	"29"/\$.ccls. and damascene and barrier adj3 (film layer metal) and first adj2 (seed metal conductive) same plasma and second adj2 (seed metal conductive)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/18 15:55